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Description

FIELD OF THE INVENTION

This invention relates to an energy-polymerizable composition comprising an ethylenically-unsaturated monomer and either polyurethane precursors or an epoxy monomer, and as Curing agent a combination of specified organometallic compound and a specified onium salt, and a method therefor. In a further aspect, cured articles comprising the composition of the invention are disclosed. The compositions are useful, for example, as protective coatings, binders for magnetic media or abrasives, adhesives, and in graphic arts applications.

Background Of The Invention

Various polymeric coatings and articles are produced in processes involving the use of organic solvents. There is an intense effort by law makers, researchers, and industry to promote high and 100% solids formulations to reduce or eliminate the use of such solvents and the attendant costs and environmental contamination. These processes require a latent catalyst or latent reaction promoter which can be activated in a controlled fashion.

Thermal curing of polyurethane precursors using reaction promoters such as tin salts and tertiaryamines is known in the art. Curing of polymerizable mixtures of polyisocyanates with polyols (referred to as polyurethane precursors) using thermally latent catalysts is known in the art (see for example U. S. Patent Hog. 4,521,545, and 4,582,861).

Photocuring of urethane (meth)acrylates is yell known (see T. A. Speckhard, K.K.S. Hwang, S.B. Lin, S.Y. Tsay, M. Koshiba, Y.S. Ding, S.L. Cooper J. Appl. Polymer Science, 1985, 30, 647-666; C. Bluestein Polym.-Plast. Technol. Eng. 1981, 17 83-93), and photocuring of polyurethane precursors using diazonium salts, tertiaryamine precursors, and organotin compounds is also known (see U.S. Patent Nos. 4,544,466, 4,549,945, and EP 28,696, Derwent abstract). All of these methods suffer from one or more of the following disadvantages: sensitivity to oxygen, requirement of ultraviolet and/or high intensity light, the need for modified resins, loss or dilution of urethane properties, low activity, poor solubility, and poor potlife.

The dual curing of acrylate/urethane precursor mixtures is known but these curing methods are not entirely photoactivated nor are any methods known that provide for the simultaneous curing of the urethane precursors and acrylates (see U.S. Pat. 4,342,793 and Roesler, Modern Paint and Coatings, April, 1986, pages 46-55).

The prior art discloses processes for the polymerization of epoxy materials. It is further known that a metallocene, such as ferrocene, can be used as a curing accelerator for epoxy materials (U.S. Patent No. 3,705,129). U.S. Patent Nos. 3,709,861, 3,714,006, 3,867,354 and 4,237,242 relate to the use of transition metal complexes in the reaction between polyepoxides and polyfunctional curing additives, but they do not teach the polymerization of epoxide group-containing compositions not containing a curing additive. The polymerization of epoxide group-containing materials is also known. Among such processes are those in which the polymerization catalyst is a radiation-sensitive onium salt of a Lewis acid (e.g. diazonium salts as is described in U.S. Patent No. 3,794,576 and U.S. Patent No. 4,080,274; halonium salts as is disclosed in U.S. Patent No. 4,026,705; and the onium salts of Group VIA elements, particularly the sulfonium salts, as are disclosed in U.S. Patent No. 4,086,091. These compositions are limited to ultraviolet radiation for polymerization. Furthermore, the dicarbonyl chelates are moisture sensitive.

U.S. Patent No. 4,216,288 teaches the thermal curing of cationically polymerizable compositions using onium salts and reducing agents.

Radiation dual curable compositions containing ethylenically unsaturated monomers and epoxy monomers have been described in U.S. Patent Nos. 4,156,035, 4,227,978, and 4,623,676. These compositions include onium salts combined with organic compounds as the curing agent, but do not contain any organometallic compounds.

Energy polymerizable compositions comprising ionic salts of organometallic complex cations and cationically sensitive materials and the curing thereof has been taught (see European Patent Application Nos. 109,851, 1984, Derwent abstract; 094,915, 1983, Derwent abstract; and 094,415, 1983, Derwent abstract).

Neutral organometallic compounds have been used in combination with neutral halogenated compounds for the photocuring of ethylenically-unsaturated monomers. (G. Smets, <u>Pure G. Appl. Chem.</u>, <u>53</u>, 611,615 (1981); H.M. Wagner, M.D. Purbrick, <u>J. Photograph Science</u>, <u>29</u>, 230-235.

EP 0 207 893 (Goodin) relates to certain titanium-containing organometallic compounds in combination with onium salts to photopolymerize epoxies and acrylates. No suggestion that metals other than Ti (Periodic Group IVB, CAS version of the Periodic Table) can be useful.

- U.S. Patent No. 4,010,289 (Kobayashi) discloses a diazonium salts and certain organometallic compounds as photopolymerization initiators for a combination of ethylenically-unsaturated and epoxy monomers.
- U.S. Patent No. 4,342,793 (Skinner) discloses interpenetrating dual cure resin compositions such as urethane precursors and acrylates cured by a combination of free radical photoinitiator (such as benzoin ethers or azo compounds) and an organotin compound. Organotin compounds do not contain a transition metal.

The use of certain photosensitizers with onium salts for initiation of polymerization of ethylenically unsaturated monomers is also well known in the art. This technique has found applications in printing, duplication, copying, and other imaging systems (see J. Kosar in Light Sensitive Systems: Chemistry and Application of Nonsilver Halide Photographic Processes, Wiley, New York, 1965, pp 158-193). Aryliodonium salts have been previously described for use as photoinitiators in addition-polymerizable compositions. (See U.S. Patent Nos. 3,729,313, 3,741,769, 3,808,006, 4,228,232, 4,250,053 and 4,428,807; H. J. Timpe and H. Baumann, Wiss Z. Tech. Hochsch. Leuna-Merseburg, 26, 439 (1984); H. Baumann, B. Strehmel, H.J. Timpe and U. Lammel, J. Prakt. Chem., 326 (3), 415 (1984); and H. Baunann, U. Oertel and H.J. Timpe, Euro. Polym. J., 22 (4), 313 (April 3, 1986).

Summary of the Invention

Briefly, the present invention provides an energy polymerizable composition comprising

- a) at least one ethylenically-unsaturated monomer,
- b) one of

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- (1) polyurethane precursors, said polyurethane precursors comprising at least an additional monomer different from a) which is at least one monomer having at least two isocyanate groups and at least one monomer having at least two isocyanate-reactive hydrogen atoms,
- (2) at least one epoxy monomer different from the monomer in a), and
- 30 c) a curing agent comprising
 - (1) an organometallic compound, and
 - (2) an onium salt selected from halonium compounds and cationic compounds of hypervalent Group VIA elements,

said organometallic compound having the formula,

L1L2L3M

wherein

L¹

represents none, or 1 to 12 ligands contributing pi-electrons that can be the same or different ligand selected from substituted and unsubstituted acrylic and cyclic unsaturated compounds and groups and substituted and unsubstituted carbocyclic aromatic and heterocyclic aromatic compounds, each capable of contributing 2 to 24 pi-electrons, to the valence shell of M;

L²

represents none, or 1 to 24 ligands that can be the same or different contributing an even number of sigma-electrons selected from mono-, di-, and tri-dentate ligands, each donating 2, 4, or 6 sigma-electrons to the valence shell of M;

 L^3

represents none, or 1 to 12 ligands that can be the same or different, each contributing no more than one sigma-electron each to the valence shell of each M;

can be bridging or non-bridging ligands;

Ligands L^1 , L^2 , and L^3 M

represents 1 to 4 of the same or different metal atoms selected from the elements of Periodic Groups IVB, VB, VIB, VIIB, and VIII when polyurethane precursors are present, or from Periodic Groups VB, VIB, VIIB, and VIII when an epoxy monomer is present in the polymerizable composition; with the proviso that said organometallic compound contains at least one of a metal-metal sigma bond and L³, and with the proviso that L¹, L², L³, and M are chosen so as to achieve a stable configuration.

The compositions are useful as protective and decorative coatings, inks, adhesives, binders for magnetic media or abrasives, in restorative and sealant applications, and in imaging applications. There is dual curing, and dual curing of the present invention contrast with curing of ethylenically-unsaturated monomers or polyurethane precursors, or epoxy monomers alone.

Advantages off compositions off the present invention when utilized in 100% reactive coating compositions include:

An industrial process innovation is disclosed that will reduce, minimize, or eliminate the generation of industrial solvent waste while reducing energy consumption.

Radiation processing, particularly utilizing electron beam and photogenerated catalysts, has potential capability for penetrating and polymerizing thick and pigmented coatings.

More readily available monomers can be used in place of functionalized oligomers (used in the prior art) thereby resulting in lower viscosity monomer solutions which are easier to coat than more viscous oligomer solutions.

Expanding the scope of curable monomers to include polyisocyanates/polyols and epoxides allows increased flexibility in designing coatings with specific properties.

In this application:

"dual curing" means the simultaneous energy-induced curing of ethylenically-unsaturated monomers in combination with one of polyurethane precursors and epoxy monomers;

"energy-induced curing" means curing by means of electromagnetic radiation (ultraviolet and visible) accelerated particles (including electron beam), and thermal (infrared and heat) means;

"ethylenically unsaturated monomer" means those monomers that polymerize by a free-radical mechanism;

"catalytically-effective amount" means a quantity sufficient to effect polymerization or the curable composition to a polymerized product at least to a degree to cause an increase in the viscosity of the composition;

"organometallic compound" means a chemical substance in which at least one carbon atom of an organic group is bonded to a metal atom ("Basic Inorganic Chemistry", F.A. Cotton, G. Wilkinson, Wiley, New York, 1976, p 497);

"polyurethane precursors" means a mixture of one or more monomers of the type including diisocyanates and polyisocyanates, and one or more monomers of the type bearing at least two isocyanate-reactive hydrogen atoms; the ratio of isocyanate groups to isocyanate-reactive hydrogen atoms is 1:2 to 2·1·

"polymerizable mixture" means a mixture where the ratio of (ethylenically-unsaturated compounds): (polyurethane precursors or epoxy compounds) is 1:99 to 99:1;

"bridging ligand" means a ligand that bonds to two or more metals in the presence or absence of metal-metal bonds;

"polyisocyanate" means an aliphatic or aromatic isocyanate having 2 or more isocyanate groups;

"polyol" means an aliphatic or aromatic compound containing 2 or more hydroxyl groups; and

"onium salt" means salts of cationic compounds of halonium, and hypervalent Group VIA elements.

Detailed Disclosure of the Invention

More specifically, in a preferred embodiment this invention describes an energy polymerizable composition comprising in the range of 99 to 1 weight percent an ethylenically-unsaturated monomer and 1 to 99 weight percent of either polyurethane precursors or an epoxy monomer and a bicomponent curing agent therefor, the curing agent comprising

1) an organometallic compound having the structure

L1L2L3M

wherein

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L¹ represents none, or 1 to 12 ligands contributing pi-electrons that can be the same or different ligand selected from substituted and unsubstituted acyclic and cyclic unsaturated compounds and groups and substituted and unsubstituted carbocyclic aromatic and heterocyclic aromatic compounds, each capable of contributing 2 to 12 pi-electrons to the valance shell of M;

L² represents none, or 1 to 24 ligands that can be the same or different contributing an even number of sigma-electrons selected from mono-, di-, and tridentate ligands, each donating 2, 4, or 6 sigma-electrons to the valence shell of M;

L³ represents none, or 1 to 12 ligands that can be the same or different, each contributing no more than one sigma electron each to the valance shell of each M;

M represents 1 to 4 of the same or different metal atoms selected from the elements of Periodic Groups IVB, VB, VIB, VIIB, and VIII (commonly referred to as transition metals) when polyurethane precursors are present or from Periodic Groups VB, VIB, VIIB, and VIII when an epoxy monomer is present in the polymerizable composition;

with the proviso that said organometallic compounds contains at least one of a metal-metal sigma bond and L³; and with the proviso that L¹, L², and L³, and M are chosen so as to achieve a stable configuration, and

2) an onium salt oxidizing agent have the structure II

AX II

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wherein

A is an organic cation of a halonium salt or an onium compound of a hypervalent Group VIA element, preferably selected from iodonium, and sulfonium cations, while more preferably A is selected from diphenyliodonium, triphenylsulfonium and phenylthiophenyl diphenylsulfonium; and

X is an anion, the counterion of the onium salts including those in which X is an organic sulfonate, or halogenated metal or metalloid, such as $CH_3SO_3^-$, $CF_3SO_3^-$, $C_6H_5SO_3^-$, p-toluenesulfonate, p-chlorobenzenesulfonate and related isomers and the like, and

those in which X has the formula DZr, wherein D is a metal from Groups IB to VIII or a metal or metalloid from Groups IIIA to VA of the Periodic Chart of Elements, Z is a halogen atom, and r is an integer having a value of 1 to 6. Preferably, the metals are copper, zinc, titanium, vanadium, chromium, manganese, iron, cobalt, or nickel and the metalloids prefereably are boron, aluminum, antimony, tin, arsenic, and phosphorous. Preferably, the halogen, Z, is chlorine or fluorine. Illustrative of suitable anions are BF_4^- , PF_6^- , ASF_6^- , SDF_6^- , FCI_4^- , SDF_5^- , SDF_5^- , AIF_6^- , $GaCI_4^-$, InF_4^- , TiF_6^- , etc. Preferably, the anions are $CV_3SO_3^-$, BF_4^- , PF_6^- , SDF_6^- , SDF_5^- , SDF_5^- , and $SDCI_6^-$.

The curing agent can be present in the range of 0.1 to 20, preferably 0.1 to 10 weight percent of the total composition. The ratio of organometallic compound to onium salt is in the range of 10:1 to 1:10 by weight, preferably 5:1 to 1:5 by weight.

The present invention also provides a process for the polymerization of ethylenically-unsaturated monomers in combination with one of polyurethane precursors and epoxy monomers comprising the steps of:

- (a) providing a mixture of at least one ethylenically-unsaturated monomers and either polyurethane precursors or an epoxy compound,
- (b) adding to said mixture a combination of a catalytically effective amount of a curing agent comprising an organometallic compound and an onium salt as specified above (and all permutations of the order of mixing the aforementioned components), thereby forming a polymerizable mixture, and
- (c) allowing the mixture to polymerize or adding energy to the mixture to effect polymerization.
- In a further aspect, there is also provided a method for preparing coated articles containing the cured composition of the invention comprising the steps of:
 - (a) providing a substrate,
 - (b) coating an energy polymerizable mixture as described above to the substrate by methods known in the art, such as bar, knife, reverse roll, knurled roll, or spin coatings, or by dipping, spraying, brushing, with or without a coating solvent, and
 - (c) applying energy (after evaporation of solvent, if present) to the article to cause the polymerization of the coating.

In a still further aspect, there are also provided shaped articles comprising the polymerizable mixture of the invention. The articles can be provided, for example, by techniques such as molding, injection molding, casting, and extrusion. Applying energy to the mixture causes polymerization and provides the cured shaped article.

It is not preferred, but it may be desirable to add solvent to solubilize components and aid in processing. Solvent, preferably an organic solvent, in an amount up to 99 weight percent, but preferably in the range of 0 to 90 weight percent, most preferably in the range of 0 to 75 weight percent, of the polymerizable composition can be used.

There are restrictions on the total sum of electrons donated by the ligands, L¹, L², L³ of formula I and the valence electrons possessed by the metal. For most organometallic compounds not involving intramolecular metal-metal bonding, this sum is governed by the "eighteen electron rule" [see J. Chem. Ed.,

46, 811 (1969)]. This rule is sometimes called the "nine orbital rule", "the effective number rule", or the "rare gas rule". This rule states that the most stable organometallic compounds tend to be those compounds in which the sum of the electrons donated by the ligands and the metal is eighteen. Those skilled in the art, however, know that there are exceptions to this rule and that organometallic compounds having a sum of 16, 17, 19, and 20 electrons are also known. Therefore, organometallic compounds not including intramolecular metal-metal bonding are described by formula I, in which complexed metals having a total sum of 16, 17, 18, 19, or 20 electrons in the valence shell are included within the scope of the invention.

For compounds described in formula I in which intramolecular metal-metal bonding exists serious departure from the "eighteen electron rule" can occur. It has been proposed [J. Amer. Chem. Soc. 100, 5305 (1978)] that the departure from the "eighteen electron rule" in these transition metal compounds is due to the metal-metal interactions destabilizing the metal p orbitals to an extent to cause them to be unavailable for ligand bonding. Hence, rather than count electrons around each metal separately in a metal cluster, cluster valence electrons (CVE) are counted. A dinuclear compound, is seen to have 34 CVEs, a trinuclear compound, 48 CVEs, and a tetranuclear compound, having tetrahedron, butterfly, and squre planar geometry is seen to have 60, 62, or 64 CVEs, respectively. Those skilled in the art, however, know that there are exceptions to this electron counting method and that organometallic complex cluster compounds having a sum of 42, 44, 46, 50 CVEs for a trinuclear compound and 58 CVEs for a tetranuclear compound are also known. Therefore, di, tri, or tetranuclear organometallic compounds are described by formula I in which the complexed metal cluster, MM, MMM, or MMMM has a total sum of 34; 42, 44, 46, 48, 50; or 58, 60, 62, 64 CVEs in the valence shell, respectively, and are included within the scope of this invention.

Illustrative examples of organometallic compounds according to formula I include:

Illustrative exampl
[CpFe(CO)₂]₂
25 Mn₂(CO)₁₀
[CpMo(CO)₃]₂
[CpW(CO)₃]₂
Re₂(CO)₁₀
Co₄(CO)₁₂
30 Co₂(CO)₈
CpFe(CO)₂SnPh₃
CpFe(CO)₂GePh₃

CpFe(CO)₂SnPh₃ CpFe(CO)₂GePh₃ [CpFe(CO)₂½SnPh₂ CpMo(CO)₃SnPh₃ (CO)₅MnSnPh₃

35 (CO)₅ MnSnPh₃ [(CO)₅ Mn]₂ SnPh₂ CpFe(CO)₂ PbPh₃ (CO)₅ MnPbPh₃ (CO)₅ ReSnPh₃

40 CpPtMe₃ CpW(CO)₃Me

Cp(CO)₃ W-Mo(CO)₃ Cp Cp(CO)₃ Mo-Mn(CO)₅

Cp(CO)₃ Mo-Re(CO)₅

45 Cp(CO)₃ W-Mn(CO)₅

Cp(CO)₃W-Re(CO)₅

Cp(CO)₃ Mo-Co(CO)₄

Cp(CO)₃W-Co(CO)₄

Cp(CO)₃ Mo-Fe(CO)₂ Cp

50 (CO)₅ Mn-Fe(CO)₂ Cp

Cp(CO)₃W-Fe(CO)₂Cp

[CpMo(CO)2PPh3]2

Mn₂(CO)₉PPh₃

Mn2(CO)8(PPh3)2

(CO)₅ Mn-Re(CO)₅

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Mn₂(CO)₈ (1,10-phenanthroline)

[CpFe(CO)2 k Si

Re₂(CO)₈(1,10-phenanthroline)

Re2(CO)8(2,2'-biquinoline) Fe₃(CO)₁₂ Ru₃(CO)₁₂ Os₃(CO)₁₂ Ru₃(CO)₁₁PPh₃ 5 Ru₃(CO)₁₀(Ph₂P-CH₂CH₂-PPh₂) Fe₂Ru(CO)₁₂ Ir4 (CO)12 [CpNi(CO)]2 CpFe(CO)2CH2Ph 10 CpFe(CO)₂(COPh) CpFe(CO)₂(SiPh₃) [CP* Fe(CO)2]2 Cp(CO)₂Fe-Fe(CO)(PPh₃)Cp (MeCp)PtMe₃ 15 (Me₃SiCp)PtMe₃ Cp(CO)₃Mo-Mo(CO)₂(PPh₃)Cp wherein Me is methyl Ph is phenyl 20 Cp is eta5-cyclopentadienyl Cp* is eta5-pentamethylcyclopentadienyl

A wide variety of monomers can be energy polymerized using the curing agent of the invention. Suitable compounds containing at least one ethylenically-unsaturated double bond, can be monomers and/or oligomers such as (meth)acrylates, (meth)acrylamides, and vinyl compounds, and are capable of undergoing addition polymerization. Such monomers include mono-, di-, or poly- acrylates and methacrylates such as methyl acrylate, methyl methacrylate, ethyl acryate, isopropyl methacrylate, n-hexyl acrylate, stearyl acrylate, allyl acrylate, glycerol diacrylate, glycerol triacrylate, ethyleneglycol diacrylate, diethyleneglycol diacrylate, triethyleneglycol dimethacrylate, 1,3-propanediol diacrylate, 1,3-propanediol dimethacrylate, trimethylolpropane triacrylate, 1,2,4-butanetriol trimethylacrylate, 1,4-cyclohexanediol diacrylate, pentaerythritol triacrylate, pentaerythritol tetraacrylate, pentaerythritol tetramethacrylate, sorbitol hexacrylate, bis[1-(2-acryloxy)]-p-ethoxyphenyldimethylmethane, bis[1-(3-acryloxy-2-hydroxy)]-p-propoxyphenyl-dimethylmethane, tris-hydroxyethylisocyanurate trimethacrylate; the bis-acrylates and bismethacrylates of polyethylene glycols of molecular weight 200-500, copolymerizable mixtures of acrylated monomers such as those of U.S. Patent No. 4,652,274, and acrylated oligomers such as those of U.S. Patent No. 4,642,126; unsaturated amides such as acrylamide, methylene bis-acrylamide, methylene bismethacrylamide, 1,6-hexamethylene bis-acrylamide, diethylene triamine tris-acrylamide and betamethacrylaminoethyl methacrylate; and vinyl compounds such as styrene, divinylbenzene diallyl phthalate, divinyl succinate, divinyl adipate, divinyl phthalate, and vinyl azlactones as disclosed in U.S. Patent No. 4,304,705. Mixtures of two or more monomers can be used if desired.

The polyisocyanate component of the polyurethane precursors that can be cured or polymerized in the dual curing systems of the present invention may be any aliphatic, cycloaliphatic, araliphatic, aromatic, or heterocyclic polyisocyanate, or any combination of such polyisocyanates. Particularly suitable polyisocyanates correspond to the formula

Q(NCO)_p III

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in which p is an integer 2 to 4, and Q represents an aliphatic hydrocarbon di-, tri-, or tetra-radical containing from 2 to 100 carbon atoms, and zero to 50 heteroatoms, a cycloaliphatic hydrocarbon radical containing from 4 to 100 carbon atoms and zero to 50 heteroatoms, an aromatic hydrocarbon radical or heterocyclic aromatic radical containing from 5 to 15 carbon atoms and zero to 10 heteroatoms, or an araliphatic hydrocarbon radical containing from 8 to 100 carbon atoms and zero to 50 heteroatoms. The heteroatoms that can be present in Q include non-peroxidic oxygen, sulfur, non-amino nitrogen, halogen, silicon, and non-phosphino phosphorus.

Examples of polyisocyanates are as follows: ethylene diisocyanate, 1,4-tetramethylene diisocyanate, 1,6-hexamethylene diisocyanate, trimethyl hexamethylene diisocyanate, 1,12-dodecane diisocyanate, cyclobutane-1,3-diisocyanate, cyclohexane-1,3- and -1,4-diisocyanate and mixtures of these isomers, 1-isocyanato-3,3,5-trimethyl-5-isocyanatomethyl cyclohexame-1,3- and -1,4-diisocyanate and mixtures of these isomers, 1-isocyanato-3,3,5-trimethyl-5-isocyanatomethyl cyclohexame-1,3- and -1,4-diisocyanate and mixtures of these isomers, 1-isocyanato-3,3,5-trimethyl-5-isocyanatomethyl cyclohexame-1,3- and -1,4-diisocyanate and mixtures of these isomers, 1-isocyanato-3,3,5-trimethyl-5-isocyanatomethyl cyclohexame-1,3- and -1,4-diisocyanate and mixtures of these isomers, 1-isocyanatomethyl-5-i

ane (see German Auslegeschrift No. 1,202,785, U.S. Patent No. 3,401,190), 2,4- and 2,6-hexahydrotolylene diisocyanate and mixtures of these isomers, hexahydro-1,3-and/or -1,4- phenylene diisocyanate, perhydro-2,4'- and/or -4,4'- diphenylmethane diisocyanate, 1,3- and 1,4-phenylene diisocyanate, 2,4- and 2,6-tolylene diisocyanate and mixtures of these isomers, diphenylmethane-2,4'- and/or - 4,4'-diisocyanate, naphthylene-1,5-diisocyanate, and the reaction products of four equivalents of the aforementioned isocyanate-containing compounds with compounds containing two isocyanate-reactive groups.

According to the present invention, it is also possible for example, to use triphenyl methane-4,4',4"triisocyanate, polyphenyl polymethylene polyisocyanates described in British Patent Nos. 874,430 and 848,671, m- and p-isocyanatophenyl sulphonyl isocyanates according to U.S. Patent No. 3,454,606, perchlorinated aryl polyisocyanates of the type described, for example, in German Auslegeschrift No. 1,157,601 (U.S. Pat. No. 3,277,138), polyisocyanates containing carbodiimide groups of the type described in U.S. Patent No. 3,152,162 and in German Offenlegungsschrift Nos. 2,504,400, 2,537,685 and 2,552,350, norbornane diisocyanates according to U.S. Patent No. 3,492,330, polyisocyanates containing allophanate groups of the type described, for example, in British Patent No. 994,890, in Belgian Pat. No. 761,626 and in Dutch Patent Application No. 7,102,524, polyisocyanates containing isocyanurate groups of the type described, for example in U.S. Patent No. 3,001,973, in German Patent Nos. 1,022,789, 1,222,067 and 1,027,394 and German Offenlegungsschrift Nos. 1,929,034 and 2,004,048, polyisocyanates containing urethane groups of the type described, for example, in Belgian Patent No. 752,261 or in U.S. Patent Nos. 3,394,164 and 3,644,457, polyisocyanates containing acrylated urea groups according to German Patent No. 1,230,778, polyisocyanates containing biuret groups of the type described, for example, in U.S. Patent Nos. 3,124,605, 3,201,372 and 3,124,605 and in British Patent No. 889,050, polyisocyanates produced by telomerization reactions of the type described for example in U.S. Patent No. 3,654,106, polyisocyanates containing ester groups of the type described, for example, in British Patent Nos. 965,474 and 1,072,956, in U.S. Patent No. 3,567,763 and in German Patent No. 1,231,688, reaction products of the above-mentioned diisocyanates with acetals according to German Patent 1,072,385 and polyisocyanates containing polymeric fatty acid esters according to U.S. Patent No. 3,455,883.

It is also possible to use distillation residues having isocyanate groups obtained in the commercial production of isocyanates, optically in solution in one or more of the above-mentioned polyisocyanates. It is also possible to use any mixtures of the above-mentioned polyisocyanates.

Preferred polyisocyanates are hexamethylene diisocyanate, its isocyanurate and its biuret; 4,4'-methylene bis(cyclohexylisocyanate); 1-isocyanato-3,3,5-trimethyl-5-isocyanatomethyl cyclohexane (isophorone diisocyanate); the tolylene diisocyanates and their isocyanurates; the mixed isocyanurate of tolylene diisocyanate and hexamethylene diisocyanate; the reaction product of 1 mol of trimethylol propane and 3 mols of tolylene diisocyanate and also crude diphenyl methane diisocyanate.

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Suitable compounds containing at least 2 isocyanate-reactive hydrogen atoms can be high or low molecular weight compounds, having a weight average molecular weight, generally from about 50 to 50,000. In addition to compounds containing amino groups, thiol groups or carboxyl groups, are, preferably, compounds containing hydroxyl groups, particularly compounds containing from about 2 to 50 hydroxyl groups and above all, compounds having a weight average molecular weight of from about 500 to 25000, preferably from about 700 to 2000, for example, polyesters, polyethers, polythioethers, polyacetals, polycarbonates, poly(meth)acrylates, and polyester amides, containing at least 2, generally from about 2 to 8, but preferably from about 2 to 4 hydroxyl groups, or even hydroxyl-containing prepolymers of these compounds and a less than equivalent quantity of polyisocyanate, of the type known for the production of polyurethanes.

Representatives of the above-mentioned compounds used in accordance with the present invention are described, for example, in High Polymers, Vol. XVI, "Polyurethanes, Chemistry and Technology", By Saunders and Frisch, Interscience Publishers, New York/London, and Vol. I, 1962, pages 32 to 42 and pages 44 to 54 and Vol. II, 1964, pages 5-6 and 198-199, and in Kunststoff-Handbuch, Vol. VII, Vieweg-Hochtlen, Carl- HanserVerlag, Munich, 1966, for example, on pages 45 to 71. It is, of course, possible to use mixtures of the above-mentioned compounds containing at least two isocyanate-reactive hydrogen atoms and having a molecular weight of from about 50 to 50,000 for example, mixtures of polyethers and polyesters.

In some cases, it is particularly advantageous to combine low-melting and high-melting polyhydroxyl containing compounds with one another (German Offenlegungsschrift No. 2,706,297).

Low molecular weight compounds containing at least two isocyanate-reactive hydrogen atoms (molecular weight from about 50 to 400) suitable for use in accordance with the present invention are compounds preferably containing hydroxyl groups and generally containing from about 2 to 8, preferably from about 2 to 4 isocyanate- reactive hydrogen atoms. It is also possible to use mixtures of different compounds

containing at least two isocyanate-reactive hydrogen atoms and having a molecular weight in the range of from about 50 to 400. Examples of such compounds are ethylene glycol, 1,2- and 1,3-propylene glycol, 1,4- and 2,3-butylene glycol, 1,5-pentane diol, 1,6-hexane diol, 1,8-octane diol, neopentyl glycol, 1,4-bis-hydroxymethyl cyclohexane, 2-methyl-1,3-propane diol, dibromobutene diol (U.S. Patent No. 3,723,392), glycerol, trimethylolpropane, 1,2,6-hexanetriol, trimethylolethane, pentaerythritol, quinitol, mannitol, sorbitol, diethylene glycol, triethylene glycol, tetraethylene glycol, higher polyethylene glycols, dipropylene glycol, higher polybutylene glycols, 4,4'-dihydroxy diphenyl propane and dihydroxy methyl hydroquinone.

Other polyols suitable for the purposes of the present invention are the mixtures of hydroxy aldehydes and hydroxy ketones ("formose") or the polyhydric alcohols obtained therefrom by reduction ("formitol") which are formed in the autocondensation of formaldehyde hydrate in the presence of metal compounds as catalysts and compounds capable of enediol formation as co-catalysts (German Offenlegungsschrift Nos. 2,639,084, 2,714,084, 2,714,104, 2,721,186, 2,738,154 and 2,738,512). Solutions of polyisocyanate polyaddition products, particularly solutions of polyurethane ureas containing ionic groups and/or solutions of polyhydrazodicarbonamides, in low molecular weight polyhydric alcohols may also be used as the polyol component in accordance with the present invention (German Offenlegungsschrift No. 2,638,759).

Many other compounds containing isocyanate-reactive hydrogen atoms and polyisocyanates are useful in the present invention, and are obvious to those skilled in the art of polyurethane science and technology.

Epoxy compounds that can be cured or polymerized in the dual systems by the curing agents of this invention, using the latter in a catalytically effective amount, are those known to undergo cationic polymerization and include 1,2-, 1,3-, and 1,4-cyclic ethers (also designated as 1,2-, 1,3-, and 1,4-epoxides). The 1,2-cyclic ethers are preferred.

The cyclic ethers which can be polymerized in accordance with this invention include those described in "Ring-Opening Polymerizations", Vol. 2, by Frisch and Reegan, Marcel Dekker, Inc. (1969). Suitable 1,2-cyclic ethers are the monomeric and polymeric types of epoxides. They can be aliphatic, cycloaliphatic, aromatic, or heterocyclic and will typically have an epoxy equivalency of from 1 to 6, preferably 1 to 3. Particularly useful are the aliphatic, cycloaliphatic, and glycidyl ether type 1,2-epoxides such as propylene oxide, epichlorohydrin, styrene oxide, vinylcyclohexene oxide, vinylcyclohexene dioxide, glycidol, butadiene oxide, glycidyl methacrylate, diglycidyl ether of bisphenol A, cyclohexeneoxide, 3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexanecarboxylate, bis(3,4-epoxy-6-methylcyclohexylmethyl)adipate, dicyclopentadiene dioxide, epoxidized polybutadiene, 1,4-butanediol diglycidyl ether, polyglycidyl ether of phenolformaldehyde resole or novolak resin, resorcinol diglycidyl ether, and epoxy silicones, e.g., dimethylsiloxanes having cycloaliphatic epoxide or glycidyl ether groups.

A wide variety of commercial epoxy resins are available and listed in "Handbook of Epoxy Resins" by Lee and Neville, McGraw Hill Book Company, New York (1967) and in "Epoxy Resin Technology" by P. F. Bruins, John Wiley & Sons, New York (1968). Representative of the 1,3- and 1,4-cyclic ethers which can be polymerized in accordance with this invention are oxetane, 3,3-bis(chloromethyl)oxetane, and tetrahydrofuran.

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In particular, cyclic ethers which are readily available include propylene oxide, oxetane, epichlorohydrin, tetrahydrofuran, styrene oxide, cyclohexeneoxide, vinylcyclohexene oxide, glycidol, glycidyl methacrylate, octylene oxide, phenyl glycidyl ether, 1,2-butane oxide, diglycidyl ether of bisphenol A (e.g., "Epon 828" and "DER 331"), vinylcyclohexene dioxide (e.g., "ERL-4206), 3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexanecarboxylate (e.g., "ERL-4221"), 3,4-epoxy-6-methylcyclohexylmethyl 3,4-epoxy-6-methylcyclohexanecarboxylate (e.g., "ERL-4201"), bis(3,4-epoxy-6-methylcyclohexylmethyl)adipate (e.g., "ERL-4289"), aliphatic epoxy modified with polypropylene glycol (e.g., "ERL-4050" and "ERL-4052"), dipentene dioxide (e.g., "ERL-4269"), epoxidized polybutadiene (e.g., "Oxiron 2001"), silicon epoxy (e.g., "Syl-Kem 90"), 1,4-butanediol diglycidyl ether (e.g., Araldite RD-2), polyglycidyl ether of phenolformaldehyde novolak (e.g., "DER-431", "Epi-Rez 521" and "DER-438"), resorcinol diglycidyl ether (e.g., "Kopoxite"), polyglycol diepoxide (e.g., "DER 736"), polyacrylate epoxide (e.g., "Epocryl U-14"), urethane modified epoxide (e.g., "QX3599"), polyfunctional flexible epoxides (e.g., "Flexibilizer 151"), and mixtures thereof as well as mixtures thereof with co-curatives, curing agents, or hardeners which also are well known (see Lee and Neville and Bruins, supra). Representative of the co-curatives of hardeners which can be used are acid anhydrides such as nadic methyl anhydride, cyclopentanetetracarboxylic dianhydride, pyromellitic anhydride, cis-1,2-cyclohexanedicarboxylic anhydride, and mixtures thereof.

As noted above, the organometallic compounds useful in combination with onium salts to provide the curing agents useful in the invention have the formula

L¹L²L³M.

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Ligands L1 to L3 are well known in the art of transition metal organometallic compounds.

Ligand L¹ of general formula I is provided by any monomeric or polymeric compound having an accessible unsaturated group, i.e., an ethylenic,

-C=C-

group; acetylenic, -C=C- group; or aromatic group which has accessible pi-electrons regardless of the total molecular weight of the compound. By "accessible", it is meant that the compound (or precursor compound from which the accessible compound is prepared) bearing the unsaturated group is soluble in a reaction medium, such as an alcohol, e.g., methanol; a ketone, e.g., methyl ethyl ketone; an ester, e.g., amyl acetate; a halocarbon, e.g., trichloroethylene; an alkane, e.g., decalin; an aromatic hydrocarbon, e.g., anisole; an ether, e.g., tetrahydrofuran; etc, or that the compound is divisible into very fine particles of high surface area so that the unsaturated group (including aromatic group) is sufficiently close to a metal atom to form a pi-bond between that unsaturated group and the metal atom. By polymeric compound, is meant, as explained below, that the ligand can be a group on a polymeric chain.

Illustrative of ligand L1 are the linear and cyclic ethylenic and acetylenic compounds having less than 100 carbon atoms, preferably having less than 60 carbon atoms, and from zero to 10 hetero atoms selected from nitrogen, sulfur, non-peroxidic oxygen, phosphorous, arsenic, selenium, boron, antimony, tellurium, silicon, germanium, and tin, such as, for example, ethylene, acetylene, propylene, methylacetylene, 1butene, 2-butene, diacetylene, butadiene, 1,2-dimethylacetylene, cyclobutene, pentene, cyclopentene, hexene, cyclohexene, 1,3-cyclohexadiene, cyclopentadiene, 1,4-cyclohexadiene, cycloheptene, 1-octene, 4octene, 3,4-dimethyl-3-hexene, and 1-decene; eta3-allyl, eta3-pentenyl, norbornadiene, eta5-cyclohexadienyl, eta⁵-cycloheptatriene, eta⁸-cyclooctatetraene, and substituted and unsubstituted carbocyclic and heterocyclic aromatic ligands having up to 25 rings and up to 100 carbon atoms and up to 10 hetero atoms selected from nitrogen, sulfur, non-peroxidic oxygen, phosphorous, arsenic, selenium, boron, antimony, tellurium, silicon, germanium, and tin, such as, for example, eta5-cyclopentadienyl, benzene, mesitylene, hexamethylbenzene, fluorene, naphthalene, anthracene, chrysene, pyrene, eta⁷ - cycloheptatrienyl, triphenylmethane, paracyclophane, 1,4-diphenylbutane, eta5-pyrrole, eta5-thiophene, eta5-furan, pyridine, gammapicoline, quinaldine, benzopyran, thiochrome, benzoxazine, indole, acridine, carbazole, triphenylene, silabenzene arsabenzene, stibabenzene, 2,4,6-triphenylphosphabenzene eta5-selenophene, dibenzostannepine, eta⁵-tellurophene, phenothiarsine, selenanthrene, phenoxaphosphine, phenarsazine, phenatellurazine, eta5-methylcyclopentadienyl, eta5-pentamethylcyclopentadienyl, and 1-phenylborabenzene. Other suitable aromatic compounds can be found by consulting any of many chemical handbooks.

As mentioned before, the ligand can be a unit of a polymer, for example, the phenyl group in polystyrene, poly(styrene-co-butadiene), poly(styrene-co-methyl methacrylate), poly(alpha-methylstyrene), polyvinylcarbazole, and polymethylphenylsiloxane; the cyclopentadiene group in poly(vinylcyclopentadiene); the pyridine group in poly(vinylpyridine), etc. Polymers having a weight average molecular weight up to 1,000,000 or more can be used. It is preferable that 5 to 50 percent of the unsaturated or aromatic groups present in the polymer be complexed with metallic cations.

Each ligand L¹ can be substituted by groups that do not interfere with the complexing of the ligand with the metal atom or which do not reduce the solubility of the ligand to the extent that complexing with the metal atom does not take place. Examples of substituting groups, all of which preferably have less than 30 carbon atoms and up to 10 hetero atoms selected from nitrogen, sulfur, non-peroxidic oxygen, phosphorus, arsenic, selenium, antimony, tellurium, silicon, germanium, tin, and boron, include hydrocarbyl groups such as methyl, ethyl, butyl, dodecyl, tetracosanyl, phenyl, benzyl, allyl, benzylidene, ethenyl, and ethynyl; hydrocarbyloxy groups such as methoxy, butoxy, and phenoxy; hydrocarbylmercapto groups such as methylmercapto (thiomethoxy), phenylmercapto (thiophenoxy); hydrocarbyloxycarbonyl such as methoxycarbonyl and phenoxycarbonyl; hydrocarbylcarbonyl such as formyl, acetyl, and benzoyl; hydrocarbylcarbonyloxy such as acetoxy, benzoxy, and cyclohexanecarbonyloxy; hydrocarbylcarbonamido, e.g., acetamido, benzamido; azo, boryl; halo, e.g., chloro, iodo, bromo, and fluoro; hydroxy; cyano; nitro; nitroso, oxo; dimethylamino; diphenylphosphino, diphenylarsino; diphenylstibine; trimethylgermyl; tributylstannyl; methylseleno; ethyltelluro; and trimethylsiloxy; condensed rings such as benzo, cyclopenta; naphtho, indeno; and the like.

Each ligand L2 in formula I is provided by monodentate and polydentate compounds preferably containing up to about 30 carbon atoms and up to 10 hetero atoms selected from nitrogen, sulfur, nonperoxidic oxygen, phosphorous, arsenic, selenium, antimony, and tellurium, whereupon addition to the metal atom, following loss of zero, one, or two hydrogens, the polydentate compounds preferably forming with the metal, M, a 4-, 5-, or 6-membered saturated or unsaturated ring. Examples of suitable monodentate compounds or groups are carbon monoxide, carbon sulfide, carbon selenide, carbon telluride, alcohols such as ethanol, butanol, and phenol; nitrosonium (i.e., NO+); compounds of Group VA elements such as ammonia, phosphine, trimethylamine, trimethylphosphine, triphenylamine, triphe sine, triphenylstibine, tributylphosphite, isonitriles such as phenylisonitrile, butylisonitrile; carbene groups such as ethoxymethylcarbene, dithiomethoxycarbene; alkylidenes such as methylidene, ethylidene; suitable polydentate compounds or groups include 1,2-bis(diphenylphosphino)ethane, 1,2-bis(diphenylarsino)ethane, bis(diphenylphosphino)methane, ethylenediamine, propylenediamine, diethylenetriamine. 1.3diisocyanopropane, and hydridotripyrrazolyborate; the hydroxycarboxylic acids such as glycolic acid, lactic acid, salicylic acid; polyhydric phenols such as catechol and 2,2-dihydroxybiphenyl; hydroxyamines such as ethanolamine, propanolamine, and 2-aminophenol; dithiocarbamates such as diethyldithiocarbamate, dibenzyldithiocarbamate; xanthates such as ethyl xanthate, phenyl xanthate; the dithiolenes such as bis-(perfluoromethyl)-1,2-dithiolene; aminocarboxylic acids such as alanine, glycine and o-aminobenzoic acid; dicarboxylic diamines as oxalamide, biuret; diketones such as 2,4-pentanedione; hydroxyketones such as 2hydroxyacetophenone; alpha-hydroxyoximes such as salicylaldoxime; ketoximes such as benzil oxime; and glyoximes such as dimethylglyoxime. Other suitable groups are the inorganic groups such as, for example, CN-, SCN-, F-, OH-, CI-, Br-, I-, and H- and the organic groups such as, for example, acetoxy, formyloxy, benzoyloxy, etc. As mentioned before, the ligand can be a unit of a polymer, for example the amino group in poly(ethyleneamine); the phosphino group in poly(4-vinylphenyldiphenylphosphine); the carboxylic acid group in poly(acrylic acid); and the isonitrile group in poly(4-vinylphenylisonitrile).

Suitable ligands L³ in formula I include any group having in its structure an atom with an unshared electron. Suitable groups can contain any number of carbon atoms and hetero atoms but preferably contain less than 30 carbon atoms and up to 10 hetero atoms selected from nitrogen, sulfur, oxygen, phosphorus, arsenic, selenium, antimony, tellurium, silicon, germanium, tin, and boron. Examples of such groups are hydrocarbyl groups such as methyl, ethyl, propyl, hexyl, dodecyl, phenyl, tolyl, etc.; unsaturated hydrocarbyl groups such as vinyl, eta¹-allyl, eta¹-butenyl, eta¹-cyclohexenyl; the hydrocarbyl derivatives of a Group IVA element such as trimethylgermyl, triphenylstannyl, trimethylsilyl, and triphenyllead, etc.; and organic groups such as formyl, acetyl, propionyl, acryloyl, octadecoyl, benzoyl, toluenesulfonyl, oxalyl, malonyl, ophthaloyl.

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Also suitable as L³ is any group having in its structure two, three, or four unshared electrons, with the proviso that only one electron is shared per metal M. Examples of such groups are CH₂, SiMe₂, SiPh₂, SnPh₂, GePh₂, SiMe, SiPh₂, SnPh, Si, and Sn.

M (subject to the requirements set out above) can be any element from the Periodic Groups IVB, VB, VIB, VIIB, and VIII, such as, for example, Ti, Zr, Hf, V, Nb, Ta, Cr, Mo, W, Mn, Tc, Re, Fe, Ru, Os, Co, Rh, Ir, Ni, Pd and Pt.

In general, radiation-induced polymerization of ethylenically unsaturated monomers and one of polyure-thane precursors and epoxy monomers with latent curing agents comprising an organometallic compound and an onium salt can be carried out at room temperature for the majority of energy curable compositions, although low temperature (e.g., -10 ° C) or elevated temperature (e.g., 30 to 200 ° C, preferably 50 to 150 ° C) can be used to subdue the exotherm of polymerization or to accelerate the polymerization, respectively. Temperature of polymerization and amount of catalyst will vary and be dependent on the particular curable composition used and the desired application of the polymerized or cured product. The amount of curing agent to be used in this invention should be sufficient to effect polymerization of the polymerizable mixtures (i.e., a catalytically-effective amount) under the desired use conditions. Such amount generally will be in the range of about 0.1 to 20 weight percent, and preferably 0.1 to 10.0 weight percent, based on the weight of curable composition.

While not wishing to be bound by theory, we propose that when specified organometallic compounds are irradiated in the presence of suitable oxidizing agents such as onium salts, intermediate compounds are produced which can affect the curing of epoxides, urethanes, and vinyl monomers. It is believed that the transition metal-transition metal or metal-L³ sigma bond cleaves homolytically upon photolysis. Evidence for this homolytic cleavage is provided for some organometallic compounds such as [CpFe(CO)₂]₂ and Mn₂-(CO)₁₀ and involves the abstraction of Cl from CCL₄ subsequent to photolysis. (G. Geoffrey and M. Wrighton, "Organometallic Photochemistry," Academic Press, NY (1979), Chapters 2 and 8, particularly p. 138). In other cases, spectroscopic data provides such evidence (O. Hackelberg, A. Wojcicki Inorg. Chem.

Acta. 1980, 44, L63; R. G. Severson, A. Wojcicki J. Organomet. Chem. 1978, 157, 173). The product(s) of this bond homolysis then react with the oxidizing agent. By this process, the catalytic species for the polymerization of either the polymerthane precursors or epoxy monomers is derived from the organometallic compound, and, simultaneously the free radical initiator for the polymerization of the ethylenically unsaturated monomers is derived from the oxidizing agent. In the limit, cleavage of the sigma bond by one photon can ultimately lead to the production of two organometallic-derived species and two free radical initiators. It should be noted that competing or secondary photo processes, such as dissociation of a carbonyl ligand, can occur. Such processes, however, occur in such a manner or to such an extent that the effective catalytic species and initiator are still produced so as to effect curing of the composition.

Solvents, preferably organic can be used to assist in dissolution of the curing agent in the ethylenically-unsaturated monomer, and either polyurethane precursors or epoxy monomers, and as a processing aid. Representative solvents include acetone, methyl ethyl ketone, cyclopentanone, methyl cellosolve acetate, methylene chloride, nitromethane, methyl formate, acetonitrile, gamma-butyrolactone, and 1,2-dimethox-yethane (glyme). In some applications, it may be advantageous to adsorb the curing agent onto an inert support such as silica, alumina, clays, etc., as deseribed in U.S. Patent No. 4,677,137.

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For those compositions of the invention which are radiation-sensitive, i.e., the compositions containing ethylenically unsaturated monomers and either polyurethane precursors or epoxy monomers and as curing agent a combination of an organometallic compound of Formula I and an onium salt of Formula II, any source of radiation including electron beam radiation and radiation sources emitting active radiation in the ultraviolet and visible region of the spectrum (e.g., about 200 to 800 nm) can be used. Suitable sources of radiation include mercury vapor discharge lamps, carbon arcs, tungsten lamps, xenon lamps, lasers, sunlight, etc. The required amount of exposure to effect polymerization is dependent upon such factors as the identity and concentrations of the organometallic compound and onium salt, the particular ethylenically unsaturated monomer, polyurethane precursors, and epoxy monomers, the thickness of the exposed material, type of substrate, intensity of the radiation source and amount of heat associated with the radiation.

Thermal polymerization using direct heating or infrared electromagnetic radiation, as is known in the art, can be used to cure ethylenically-unsaturated monomers and either polyurethane precursors or epoxy monomers according to he teachings of this invention.

It is within the scope of this invention to include two-stage polymerization (curing), by first activating curing agent by irradiating the curable compositions and subsequently thermally curing the activated precursor so obtained, the irradiation temperature being below the temperature employed for the subsequent heat-curing. These activated precursors may normally be cured at temperatures which are substantially lower than those required for the direct thermal curing, with an advantage in the range from 50 to 110 °C. This two-stage curing also makes it possible to control the polymerization in a particularly simple and advantageous manner.

Adjuvants such as solvents, pigments, abrasive granules, stabilizers, light stabilizers, antioxidants, flow agents, bodying agents, flatting agents, colorants, inert fillers, binders, blowing agents, fungicides, bacteriocides, surfactants, plasticizers, and other additives as known to those skilled in the art can be added to the compositions of this invention. These can be added in an amount effective for their intended purpose.

Compositions of this invention are useful for coatings, foams, shaped articles, adhesives, filled or reinforced composites, abrasives, caulking and sealing compounds, casting and molding compounds, potting and encapsulated compounds, impregnating and coating compounds, and other applications which are known to those skilled in the art.

Compositions of this invention may be applied, preferably as a liquid, to a substrate such as steel, aluminum, copper, cadmium, zinc, glass, paper, wood, or various plastic films such as poly(ethylene terephthalate), plasticized poly(vinylchloride), poly(propylene), poly(ethylene), and the like, and irradiated. By polymerizing part of the coating, as by irradiation through a mask, those sections which have not been exposed may be washed with a solvent to remove the unpolymerized portions while leaving the photopolymerized, insoluble portions in place. Thus, compositions of this invention may be used in the production of articles useful in the graphic arts such as printing plates and printed circuits. Methods of producing printing plates and printed circuits from photopolymerizing compositions are well known in the art (see for example British Patent Specification No. 1,495,746).

Objects and advantages of this invention are further illustrated by the following examples, but the particular materials and amounts thereof recited in these examples, as well as other conditions and details, should not be construed to unduly limit this invention. In the examples, all parts are parts by weight unless indicated otherwise. All examples were prepared in ambient atmosphere (presence of oxygen and water) unless indicated otherwise. In the examples:

Me = methyl

Ph = phenyl

Cp = cyclopentadienyl

EXAMPLE 1

The organometallic compounds, [CpFe(CO)₂]₂, Mn₂(CO)₁₀, Re₂(CO)₁₀ and [CpMo(CO)₃]₂ were obtained from Pressure Chemical Company and used without further purification. The other compounds were prepared using standard organometallic synthetic techniques. The procedure used will be illustrated for the preparation of CpFe(CO)₂SnPh₃.

The anion, CpFe(CO)₂, was produced by reducing 3.0g of [CpFe(CO)₂]₂ with 0.41g of sodium and 0.50g of benzophenone in 200 mL of freshly distilled tetrahydrofuran under an atmosphere of argon. The reaction was allowed to proceed for about 24 hours by which time the starting material had all been reduced to the anion as indicated by infrared spectroscopy (IR). To the solution of the anion was added, under argon, 6.5 g of ClSnPh₃ as a solid. The reaction was stirred until the anion was consumed as shown by IR. The reaction vessel was opened to air and the solvent removed under reduced pressure. The solid residue was taken up in methylene chloride and passed down a short silica gel column. Crytals were obtained by removing the methylene chloride under reduced pressure and adding heptane. The product was identified by IR, nuclear magnetic resonance spectroscopy (NMR), elemental analysis and melting point. In a similar manner all the other materials in Table I were prepared.

These compounds are used in subsequent examples.

TABLE I

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Characterization of Compounds			
Compound	Elemental Analysis (Report/Calculated)		Melting Point (°C)
	%C	% H	
CpFe(CO)₂SnPh₃	57.0/57.0	3.8/3.8	135-136
CpFe(CO)₂GePh₃	62.3/62.4	4.2/4.2	159-160
CpFe(CO)₂PbPh₃			
[CpFe(CO) ₂] ₂ SnPh ₂	49.7/49.8	3.3/3.2	146-149
(CO) ₅ MnSnPh₃	51.0/50.7	2.8/2.8	146-149
(CO) ₅ MnPbPh ₃			
[(CO) ₅ Mn] ₂ SnPh ₂	39.9/39.8	1.6/1.5	138-139
(CO)₅ ReSnPh₃			
CpMoSnPh₃	52.6/52.5	3.4/3.4	213-214

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EXAMPLE 2

Several organometallic compounds were prepared according to literature methods. CpW(CO)₃(CH₃) was prepared according to the method of T.S. Piper, G. Wilkinson, Inorg. Nucl. Chem., 1956, 3, 104-124. [CpW-(CO)₃]₂ was prepared according to the method of R. Birdwhistell, P. Hackett, A. R. Manning, J. Organomet. Chem., 1978, 157, 239. CpFe(CO)₂SiPh₃ was prepared according to the method of G. Cerveau, E. Colomer, R. Corriv, W. E. Douglas, J. Organomet. Chem., 1977, 135, 373, 386. The method of J. P. Bibler, A. Wojcicki, J. Amer. Chem. Soc., 1966, 88, 4862 was used to prepare CpFe(CO)₂(CHPh₂), and that of R. B. King, M. B. Bisnette, J. Organomet. Chem., 1964, 2, 15-37, to prepare CpFe(CO)₂(COPh). The preparation of CpPtMe₃ has been described in U.S. Patent No. 4,600,484.

These compounds are used in subsequent examples.

EXAMPLE 3

This example describes the photocuring of Henkel Duo-Cure [™] (Henkel Corp., Minneapolis, MN) resins. The Henkel Duo-Cure [™] resins are polyol/aliphatic polyisocyanate and multifunctional acrylate systems containing no curing agents. The resins are dual curing resins, and are claimed to form interpenetrating networks (IPN's) when properly cured.

Samples were prepared, 2.0 g in size, using 77 parts Henkel Duo-Cure 172A, 23 parts Duo-Cure 172B, 0.5 parts [CpFe(CO)₂]₂, and 1 part Ph₂I⁺ PF₆-. One sample was cured in the vial using a suntan lamp, cured in <3.0 minutes to a clear, hard mass. The other sample was coated on a tongue depressor and exposed to the suntan lamp. Curing occurred in 15 seconds, to yield a clear, hard, sandable coating. Infrared spectra of thin coatings on salt plates showed conversion of the isocyanate to urethane upon exposure to sunlamp radiation.

EXAMPLE 4 (Comparative)

This example illustrates the photocuring of polyurethane precursors to polyurethanes in the presence and absence of O₂ using transition metal-transition metal bond containing organometallic compounds and onium salt as curing agent.

A mixture of 10 mg [CpFe(CO)₂]₂, 30 mg Ph₂I⁺ PF₆-, 0.1 g gamma-butyrolactone, 0.83 g DesmodurTM W (4,4'- methylenebis(cyclohexylisocyanate)), and 1.17 g polyethyleneglycol (MW = 400) was divided in half. One half was bubbled with N₂ for 2-3 minutes, the other left open to the atmosphere. Both samples were irradiated simultaneously with the output of a 450 watt Hanovia mercury lamp, filtered through Pyrex and a water infrared filter. Both samples cured after 10.0 minutes irradiation. This demonstrates that in the presence of onium salt, curing occurs with or without O₂ present.

20 EXAMPLE 5 (Comparative)

This example describes the photocuring of polyurethane precursors using transition metal containing organometallic compounds and iodonium and sulfonium salts. A stock solution was prepared from 7 parts Desmodur W, 1.9 parts butanediol, and 0.5 parts trimethylolpropane. Samples were prepared as in Example 3 using 1.25 g of the stock solution, 0.01 g neutral metal-metal bonded compound and 0.015 g Ph₂I⁺ PF₆-in 0.05 g gamma-butyrolactone. Irradiations were carried out on a 450 W Hanovia medium pressure mercury arc through Pyrex. Alternatively, these compositions can be cured thermally.

TABLE II

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Iodonium and Sulfonium Salts Organometallic Compound Cure time, minutes Ph2I+ PF6-Ph₃S⁺ PF₆-[Co(CO)4]2 6.0 >100 20-25 [CpFe(Co)₂]₂ 9.0 [Mn(CO)₅ }₂ 12-20 7-12 [Re(Co)₅]₂ 20-40 20-40 CO4 (CO)12 40-55 55-66 [CpMo(CO)₃]₂ 55-67 60-66 Fe₂(CO)₉ ca. 60

EXAMPLE 6 (Comparative)

This provides further examples of bicomponent curing agents wherein organometallic compounds contain transition metal-carbon bonds which are effective in the curing agent for polyurethane precursors. A stock solution of polyurethane precursors was prepared by mixing 23.1 g Desmodur W and 32.6 g Carbowax 400 and shaking well before use. Samples were prepared by dissolving 10 mg catalyst and 20 mg diphenyliodonium hexafluorophosphate (if used) in 0.2 g CH₂Cl₂. 2.0 g stock solution was added in the dark, and samples were then irradiated under a Hanovia Quartz Utility Lamp. The temperature of samples under the lamp reached ca. 50 °C within 10 min. The time to a viscocity increase is noted in Table III, and "cure time" is the time for a sample to become so viscous that it would not flow. "Partial cure" is indicated when, within 30 min irradiation, the sample became more viscous but would still flow.

TABLE III

Curing of Polyurethane Precursors Cure Rates. min Viscocity Increase Cured 7 30 CpPtMe₃ CpPtMe₃ + iodonium 7 30 30 CpW(CO)₃Me partial CpW(CO)₃Me + iodonium 30 partial [(PMe₂Ph)₂PtMe₃(acetone)] + PF₆-a 13 partial [CpFe(CO)₂)]₂ + iodonium^a 9 30

a included for purposes of comparison

The data show curing occurs with or without iodonium salts. In some cases, adventitious oxygen can provide a suitable oxidizing agent. However, the use of onium salts is preferred since it is much easier to control the organometallic/oxidizing agent ratio.

EXAMPLE 7 (Comparative)

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This example demonstrates the ability of transition metal-transition metal bonded or ML³ type organometallic compounds to photoinitiate the cure of ethylenically-unsaturated compounds in the presence of iodonium salts. The tests were carried out in the following manner: Into a glass vial were weighed out 0.05g of the desired organometallic compound and/or 0.10g diphenyliodonium hexafluorophosphate (3M Company, recrystallized from acetone/isopropanol). Then, the following operations were carried out under subdued light: 0.2g of gamma-butyrolactone, 5.0g methyl acrylate (Aldrich Chemical Company, distilled from hydroquinone), 5.0g of pentaerythritol tetraacrylate (SR-295, Sartomer Company) were added to prepare the coating solution. The solutions were coated onto 76 micrometers (3 mil) polyvinylidene chloride subbed polyester (3M Company) using a #22 wire wound rod. The sample coatings were overlayed with a second sheet of polyester and exposed to two 15 watt Sylvania blacklight bulbs at a distance of 2 cm. The time required to produce a nontacky cured coating was recorded. Under the conditions of this test, the diphenyliodonium hexafluorophosphate alone requires greater than 15 min to cure.

TABLE IV

Curing of Ethylenically Unsaturated Monomers			
Organometallic Compound	Cure Time ^a		
	No Onium Salt Added	Onium Salt Added	
[CpFe(Co) ₂] ₂	>600	15	
CpFe(CO)₂SnPh₃	>600	120	
CpFe(CO)₂GePh₃	>600	120	
[CpFe(CO) ₂] ₂ SnPh ₂	>600	60	
Mn ₂ (CO) ₁₀	>600	<15	
(CO)₅ MnSnPh₃	300	300	
[(CO) ₅ Mn] ₂ SnPh ₂	60	30	
Re ₂ (CO) ₁₀	120	60	
[CpMo(CO)₃ ½b	>600	30	
CpMo(Co) ₃ SnPh ₃	>600	240	

a time in seconds to cure.

b saturated solution, <0.01g dissolved.

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EXAMPLE 8 (Comparative)

Further examples of the curing of ethylenically unsaturated monomer (25 g of pentaerythritol tetraacrylate in 225g acetonitrile) or epoxy monomer (cyclohexene oxide) are provided here. A curable composition consisted of 0.01g of the organometallic compound or 0.02g of diphenyliodonium hexafluorophosphate or these same amounts of both compounds added to either monomer. The light sources used were for UV exposure, about 360 nm, two 15 watt G.E. blacklite bulbs and for the visible, a Kodak Carousel Projector or the projector with a 440 nm filter. The initiation of polymerization was detected by solution gelation for the acrylate and for the epoxy the precipitation of the polymer from a 2% ammonia/methanol solution. Free radical systems were purged with N_2 for 2 minutes before and continuously during irradiation while the cationic samples were left open to the air without purging. Sample size was 2 to 3 ml in a 13 x 100 mm pyrex test tube. The results of these tests are shown in Table V.

Table V

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EXAMPLE 9 (Comparative)

Photoinitiated Cure Times of Epoxy and Acrylate Compositions^a **Curing Agent** Ероху Acrylate [CpFe(CO)₂]₂ >180^b >300b 90p <5b <5^d 90^d [CpFe(CO)₂]₂/iodonium^c >300b >180^b Mn₂(CO)₁₀ >180e >300e >180b <10^b Mn₂(CO)₁₀/iodonium^c >180e <10°

a Cure times given in seconds.b Unfiltered projector as light source.

c The diphenyliodonium salt showed no indication of polymerization by itself under these same conditions.

d 440 nm filter used with the projector.

e Blacklite used as the light source, about 360 nm.

Examples of the photocuring of ethylenically unsaturated monomers using transition metal-transition metal bond containing organometallic compounds and iodonium salts are given here.

Samples were prepared as 1.0 g methyl acrylate containing 0.01 g metal-metal bond containing complex and 0.015 g Ph_2I^+ PF_5 -. Up to 0.05 g butyrolactone or methylene chloride were used to dissolve the photocatalyst systems. Samples were bubbled with N_2 and irradiated using a Kodak Carousel slide projector, with a 360 nm cutoff filter, and the time required to cure the sample recorded in Table VI. Alternatively, compositions could be cured thermally.

TABLE VI

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Curing of Ethylenically-Unsaturated Monomers Compound and Ph2I+PF6-Conditions Cure Time [CpFe(CO)₂]₂ irrad. 30 Sec. slow dark reaction Mn₂(CO)₁₀ 30 sec, no dark reaction irrad. [CpMo(CO)₃]₂ irrad. 45 sec, no dark reaction [Re(CO)₅ ½ irrad. 8 min. no dark reaction Co4(CO)₁₂ irrad. Minutes, slow dark reaction Co2 (CO)₈ Dark Cures during deoxygenation

EXAMPLE 10 (Comparative)

This example describes the curing of ethylenically unsaturated monomers with transition metal-carbon bonded organometallic compounds. Each sample was prepared by dissolving 10 mg catalyst and 20 mg diphenyliodonium hexafluorophosphate (if used) in 0.2 g gamma-butyrolactone. 2.0 g methyl acrylate (distilled to remove inhibitors) was added in the dark and nitrogen was bubbled through the sample for 2 min to remove oxygen. Samples were then irradiated in front of a Kodak Carousel Projector containing a 360 nm cutoff filter. If no curing occurred in 15 min, the sample was then irradiated for 15 min under a Hanovia Quartz Utility lamp. In Table VII, "cure time" refers to the time required for a sample to solidify. Alternatively, compositions could be cured thermally.

TABLE VII

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Curing of Ethylenically Unsat	turated Monomer
Curing Agent	Cure time, min
CpPtMe ₃ CpPtMe ₃ + iodonium CpW(CO) ₃ Me CpW(CO) ₃ Me + iodonium [CpFe(CO) ₂ ½ + iodonium ^a	15 (Hanovia) 6 (Kodak) no cure 3.5 0.5 (dark cure)

a included for purposes of comparison

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EXAMPLE 11 (Comparative)

This example describes the use of [CpW(CO)₃]₂ to cure polyurethane precursors, epoxies or ethylenically unsaturated monomers. Each sample contained 0.01 g [CpW(CO)₃]₂ and 0.02 g diphenyliodonium hexafluorophosphate (if used) in 0.25 g gamma-butyrolactone, to which was added 2.0 g of precursor or monomer in a vial. Irradiation was then performed with a Kodak Carousel Projector (9 inches away), modified with a 360 nm filter. With a urethane precursor stock solution (prepared as in Example 4), in the presence or absence of onium salt, partial curing to produce a clear solution, occurred in 2 hour irradiation time. Upon standing in room light for 24 hours, an increase in viscosity occurred.

When cyclohexeneoxide was used, and the curing agent consisted of [CpW(CO)₃]₂ and onium salt, vigorous, exothermic curing occurred within 3 min of irradiation.

When methyl acrylate was used as monomer, no curing occurred in the absence of onium salt. With onium salt present, the sample became viscous within 4 min and solid within 8 min of irradiation time.

Alternatively, these compositions can be cured thermally.

EXAMPLE 12 (Comparative)

To demonstrate the utility of the curing agent for curing of polyurethane precursors, epoxies and vinyl monomers for the case where the organometallic compound contains a single bond between a transition metal and a Group IVA element, the following samples were prepared. In a vial, 0.01 g of organometallic compound, 0.02 g of diphenyliodonium hexafluorophosphate (if used, as indicated below), and 0.25 g of gamma-butyrolactone were gently agitated until dissolution of the organometallic compound was complete. 2.0 g of polyurethane precursors or monomer was added in reduced light, the vial was capped, and the sample irradiated in front of a Kodak Carousel projector fitted with a 360 nm cutoff filler at a distance of nine inches, and at room temperature (about 25 °C). Particular details and any experimental variations are indicated in Table VIII.

TABLE VIII

Cure Times: Photoinitiated Curing of Polyurethane
Precursors Epoxies and Vinyl Monomers with Transition

Metal-Group IVA Compounds

	<u>Catalyst System</u>	Pol	yUre	<u>thane</u> '		<u>Vinyl</u> c
10	[CpFe(CO) ₂] ₂ d	120	min	(VV)	f	no cure
	[CpFe(CO) ₂] ₂ /iodonium ^d	60	min	(VV)	30 sec	1.8 min
	CpFe(CO) ₂ (CH ₂ Ph)	40	min	(V)	£	no cure
	CpFe(CO) ₂ (CH ₂ Ph)/iodonium	40	min	(V)	12 min	23 min
15	CpFe(CO) ₂ (COPh)	120	min	(V) e	f	no cure
	CpFe(CO) ₂ (COPh)/iodonium	120	min	(V) e	5 min	48 hr g
	CpFe(CO) ₂ (SiPh ₃)	45	min	(V) h	f	no cure
20	CpFe(CO) ₂ (SiPh ₃)/iodonium	45	min	(V) ^h	5 min	48 hr g
20	CpFe(CO) ₂ (GePh ₃)	36	min	(V) h	f	no cure
	CpFe(CO) ₂ (GEPh ₃)/iodonium	36	min	(V) ^h	2.75 min	no cure
	CpFe(CO) ₂ (SnPh ₃)	36	min	(S) ^h	f	no cure
25	CpFe(CO) ₂ (SnPh ₃)/iodonium	36	min	(V) h	2 min	no cure
	CpFe(CO) ₂ (PbPh ₃)	45	min	(S) ^h	f	no cure
	CpFe(CO) ₂ (PbPh ₃)/iodonium	33	min	(VV)h	no cure	no cure

- a. Polyurethane precursors are from a stock solution consisting of 23.1 g of DesmodurTM W and 32.6 g of Carbowax 400. Cure times are followed by an indication in parentheses of extent of cure, where V = viscous, VV = very viscous, S = solid.
 - b. Monomer is cyclohexene oxide, purified by distillation. Cure time is defined as the time necessary to observe formation of precipitate when one drop of sample is placed in 2 ml of methanol.
 - c. Monomer is methyl acrylate, purified prior to use by distillation under reduced pressure. After monomer addition but before irradiation, samples were deoxygenated by bubbling a stream of nitrogen gas through the solution for 2 min, with care being taken to prevent any light from reaching the sample during deoxygenation. Cure is defined by an increase in solution viscosity or a sudden

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- exotherm indicating rapid polymerization (also accompanied by a sudden increase in viscosity).
- d. Included for purposes of comparison to data in other Tables.
- e. 60 min irradiation with Carousel Projector, followed by 60 minutes of irradiation in room (fluorescent) light.
- f. This particular combination was not tested.
- g. 30 minutes irradiation with Kodak projector, following by 30 minutes irradiation under a Hanovia Quartz Utility Lamp (6 inches from bulb), followed by sample storage/irradiation in room (fluorescent) light.
- h. Irradiation with Hanovia Quartz Utility Lamp (15 cm from bulb) in place of the Kodak Projector.

25 EXAMPLE 13

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This example illustrates the dual curing of polyurethane precursors and ethylenically-unsaturated monomers using the curing agent [CpFe(CO)₂]₂/Ph₂I⁺ PF₆-.

Samples 1.25 g in size, were prepared from stock solutions of 2.08 parts Desmodur W (4,4'methylenebis(cyclohexylisocyanate)), 2.92 parts polyethyleneglycol (MW = 400), 5.0 parts methyl acrylate
(freshly distilled), and 0.05 parts [CpFe(CO)₂]₂. To half of this stock solution was added 0.062 parts Ph₂I⁺
PF₅-. Mole ratios for iodonium salt/iron dimer = 2.1, NCO/OH = 1.0, weight % iron dimer = 0.5%,
iodonium salt = 1.2%. Samples were irradiated simultaneously using 366 nm BlakRay bulbs (15 watts) for
10 min, then analyzed by 400 MHz ¹H nuclear magnetic resonance spectroscopy. Conversions to polymer
are listed in Table IX. Curing agents comprising other combinations of organometallic compounds and
onium salts can be used in place of [CpFe(CO)₂]₂ and Ph₂IPF₅, respectively.

TABLE IX

Onium Salt	Conditions Conv		ersion to polymer	
		Acrylate	Urethane	
Ph ₂ I ⁺	Dark		4%	
Ph ₂ I ⁺	Irradiation	79%	56%	
Ph₂I ⁺	Irradiation, deoxygenated	76%	8%	
None	Dark	0%	11%	
None	Irradiation	24%	75%	
None	Irradiation, deoxygenated	trace	10%	

EXAMPLE 14

This example demonstrates simultaneous curing of ethylenically unsaturated monomers and epoxies. Gelation times will not show that both monomers have reacted at the same time. It is possible to use nuclear magnetic resonance spectroscopy to differentiate the two polymers in the presence of each other. The experiment was carried out in the following manner: A 1/1, w/w, mixture of methyl acrylate/cyclohexene

oxide was prepared. To a 10g sample of this mixture was added 0.01g of [CpFe(CO)₂]₂ or Mn₂(CO)₁₀ diphenyliodonium hexafluorophosphate (0.024g with the iron dimer, 0.03 g with the manganese dimer) or specified amounts of both compounds. In a small vial was placed 2 ml of the sample and it was purged for 1 min before and continually during irradiation. The light source was two 15 watt G.E. blacklite bulbs. Irradiation time was 2 minutes. Immediately after completion of the photolysis, the NMR in CDCl₃ was taken. The amount of polymerization was determined by the ratio of the peak intensity of the polymer to that of polymer plus monomer. The results of the study are shown in Table X.

TABLE X

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Percent Conversion to Poly	mer from N	MR Study
Curing Agent	Ероху	Acrylate
[CpFe(CO) ₂] ₂	Ор	18
[CpFe(CO) ₂] ₂ /iodonium	35	60
iodonium	<5	<10
Mn ₂ (CO) ₁₀	<0.5	<0.5
Mno(CO), o (indonium	37	l 47

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As can be seen from the NMR results, this system efficiently initiated both epoxy and free radical polymerization simultaneously. Curing agents comprising other combinations of organometallic compounds and onium salts can be used in place of [CpFe(CO)₂]₂ and Mn₂(CO)₁₀, and Ph₂IPF₆, respectively.

EXAMPLE 15

This example demonstrates the simultaneous curing of ethylenically unsaturated and epoxy monomers in a crosslinkable system. The curable composition consists of methyl acrylate, cyclohexene oxide and glycidyl acrylate. If only epoxy or acrylate cure are initiated, then this system will produce a soluble polymer. Only if both epoxy and acrylate cure are initiated will a crosslinked insoluble polymer be produced.

All monomers were distilled before use; methyl acrylate and glycidyl acrylate from hydroquinone. Sample preparations were carried out under subdued lights. The polymerizable mixture consisted of 0.2 g gamma-butyrolactone, 1.0 g glycidyl acrylate, 5.0 g methyl acrylate and 5.0 g cyclohexene oxide. Depending on the test, added to this were 0.05 g of the desired organometallic compound and/or 0.1 g diphenyliodonium hexafluorophospnate. A 3 g portion of this composition was placed in a glass vial and irradiated between two 15 watt G.E. daylight fluorescent bulbs using an Ultraviolet Products lamp holder (lamp separation distance 4 cm). The sample was purged with nitrogen for one minute preceeding and continuously during photolysis. The irradiation time required to produce a polymer insoluble in chloroform was recorded, and is noted in Table XI. Alternatively, these compositions can be cured thermally.

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a NMR's taken on a 400 MHz instrument.

b None detected in the NMR.

TABLE XI

Compound	Cure Time ^a	
	No Onium Salt Added	Onium Salt Added
[CpFe(CO) ₂] ₂	>15	1
CpFe(CO)₂SnPh₃	>15	10
CpFe(CO) ₂ GePh ₃	>15	15
[CpFe(CO) ₂] ₂ SnPh ₂	>15	10
Mn ₂ (CO) ₁₀	>15	1.5
(CO)₅ MnSnPh₃	>15	10
[(CO) ₅ Mn] ₂ SnPh ₂	>10	4
Re ₂ (CO) ₁₀	>10	5
[CpMo(CO)₃ ½b	>15	1.5
Cpho(CO) ₃ SnPh ₃	>15	10

a time in minutes to produce insoluble crosslinked system. Diphenyliodonium hexafluorophosphate alone under these conditions does not produce a crosslinked system after 15 minutes.

Various modifications and alternations of this invention will become apparent to those skilled in the art without departing from the scope and spirit of this invention, and it should be understood that this invention is not to be unduly limited to the illustrative embodiments set forth herein.

Claims

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- An energy polymerizable composition comprising
 - a) at least one ethylenically-unsaturated monomer,
 - b) one of
 - (1) polyurethane precursors, said polyurethane precursors comprising at least an additional monomer different from a) which is at least one monomer having at least two isocyanate groups and at least one monomer having at least two isocyanate-reactive hydrogen atoms,
 - (2) at least one epoxy monomer different from the monomer in a), and
 - c) a curing agent comprising
 - (1) an organometallic compound, and
 - (2) an onium salt selected from halonium compounds and cationic compounds of hypervalent Group VIA elements,

said organometallic compound having the formula,

L1L2L3M

45	wherein	
	ני	represents none, or 1 to 12 ligands contributing pi-electrons that can be the same or different ligand selected from substituted and unsubstituted acyclic and cyclic unsaturated compounds and groups and substituted and unsubstituted carbocyclic aromatic and heterocyclic aromatic compounds,
50	L ²	each capable of contributing 2 to 24 pi-electrons to the valence shell of M; represents none, or 1 to 24 ligands that can be the same or different contributing an even number of sigma-electrons selected from mono-, di, and tridentate ligands, each donating 2, 4, or 6 sigma-electrons to the valence shell of M;
55	L ³	represents none, or 1 to 12 ligands that can be the same or different, each contributing no more than one sigma-electron each to the valence shell of each M;
	Ligands L ¹ , L ² , and L ³	can be bridging or non-bridging ligands;

b Only 0.01g of this compound used.

М

represents 1 to 4 of the same or different metal atoms selected from the elements of Periodic Groups IVB, VB, VIB, VIIB, and VIII when polyure-thane precursors are present, or from Periodic Groups VB, VIB, VIIB, and VIII when an epoxy monomer is present in the polymerizable composition; with the proviso that said organometallic compound contains at least one of a metal-metal sigma bond and L³, and with the proviso that L¹, L², L³, and M are chosen so as to achieve a stable configuration.

2. The composition according to claim 1 wherein said onlum salt has the formula II

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AX II

wherein

- A is an iodonium, or sulfonium cation, and
- X is an organic sulfonate counterion, or a halogenated metal or metalloid counterion.
- The composition according to claims 1 to 2 wherein said ethylenically-unsaturated monomer is selected from the group consisting of acrylates, acrylamides and vinyl compounds.
- 4. The composition according to claims 1 to 3 wherein said polyurethane precursors comprise a mixture of polyisocyanates and compounds bearing at least two isocyanate-reactive hydrogen atoms where the ratio of isocyanate groups to isocyanate-reactive hydrogen atoms is in the range of 1:2 to 2:1.
 - 5. A process comprising the steps of:
 - a) providing a polymerizable mixture according to claims 1 to 4, and
 - b) allowing said mixture to polymerise or adding energy to said mixture to effect polymerization.
 - A layered structure comprising a substrate having coated on one surface thereof the polymerizable composition according to claims 1 to 4.

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- 7. The layered structure according to claim 6 which is an imageable structure.
- 8. A shaped article comprising the composition according to claims 1 to 4.
- 5 9. The composition according to claims 1 to 4 and 6 to 8 which has been cured.

Patentansprüche

- 1. Mit Energie polymerisierbare Zusammensetzung, umfassend:
 - (a) mindestens ein ethylenisch ungesättigtes Monomer,
 - (b) entweder
 - (1) Polyurethan-Präkursoren, umfassend mindestens ein von (a) verschiedenes, zusätzliches Monomer, welches mindestens ein Monomer mit zwei Isocyanatgruppen und mindestens ein Monomer mit mindestens zwei mit Isocyanat reaktionsfähigen Wasserstoffatomen umfaßt, oder
 - (2) mindestens ein vom Monomer unter (a) verschiedenes Epoxy-Monomer sowie
 - (c) ein Härtungsmittel, umfassend:
 - (1) eine organometallische Verbindung und
 - (2) ein Oniumsalz, ausgewählt aus Halonium-Verbindungen und kationischen Verbindungen von hypervalenten Elementen der Gruppe VIA, welche organometallische Verbindung die Formel hat:

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L1L2L3M

worin

L¹ keinen oder 1 bis 12 Liganden darstellt, die π-Elektronen beitragen und die gleich oder verschieden sein können, ausgewählt aus substituierten und nichtsubstituierten acyclischen und cyclischen ungesättigten Verbindungen und Gruppen sowie substituierten und nichtsubstituierten carbocyclischen aromatischen und heterocyclischen aromatischen Verbindungen, von denen jede zwei bis 24 π-Elektronen zur M-Valenzschale beitragen kann;

- L² keinen oder 1 bis 24 Liganden darstellt, die gleich oder verschieden sein können und eine gerade Zahl von Sigma-Elektronen beitragen, ausgewählt aus unidentalen, bidentalen oder tridentalen Liganden, von denen jeder 2, 4 oder 6 Sigma-Elektronen an die Valenzschale von M abgibt;
- L³ keinen oder 1 bis 12 Liganden darstellt, die gleich oder verschieden sein können, von denen jeder nicht mehr als jeweils ein Sigma-Elektron zu jeder Valenzschale von M beiträgt;
 - die Liganden L1, L2 und L3 brückenbildende oder nichtbrückenbildende Liganden sein können;
- M 1 bis 4 gleiche oder verschiedene Metallatome darstellt, ausgewählt aus den Elementen der Gruppen IVB, VB, VIB, VIIB und VIII des Periodensystems der Elemente, wenn Polyurethan-Präkursoren vorliegen, oder der Gruppen VB, VIB, VIIB und VIII des Periodensystems der Elemente, wenn in der polymeriserbaren Zusammensetzung ein ein Epoxy-Monomer vorliegt;
- unter der Voraussetzung, daß die organometallische Verbindung mindestens eine Metall-Metall-Sigmabindung und L^3 enthält, sowie
- unter der Voraussetzung, daß L¹, L², L³ und M so ausgewählt werden, daß eine stabile Konfiguration erzielt wird.
- 2. Zusammensetzung nach Anspruch 1, bei welcher das Oniumsalz die Formel II hat:

AX II

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- worin A ein Iodonium-, Sulfonium- oder Diazonium-Kation ist und X ein organisches Sulfonat-Gegenion oder ein halogeniertes Metall- oder Nichtmetall-Gegenion ist.
 - 3. Zusammensetzung nach Anspruch 1 und 2, bei welcher das ethylenisch ungesättigte Monomer ausgewählt wird aus der Gruppe, bestehend aus Acrylaten, Acrylamiden und Vinylverbindungen.
 - 4. Zusammensetzung nach Anspruch 1 bis 3, bei welcher die Polyurethan-Präkursoren eine Mischung von Polyisocyanaten und Verbindungen umfassen, die mindestens zwei mit Isocyanat reaktionsfähige Wasserstoffatome umfassen, wobei das Verhältnis von Isocyanatgruppen zu mit Isocyanat reaktionsfähigen Wasserstoffatomen im Bereich von 1:2 bis 2:1 liegt.
- Verfahren, umfassend die Schritte von:
 - (a) Schaffen einer Mischung nach Anspruch 1 bis 4 und
 - (b) Polymerisierenlassen der Mischung oder Hinzufügen von Energie zu der Mischung, um Polymerisation zu bewirken.
 - 6. Schichtstruktur, umfassend ein Substrat, auf dessen eine Seite die polymerisierbare Zusammensetzung nach Anspruch 1 bis 4 aufgetragen ist.
 - 7. Schichtstruktur nach Anspruch 6, die eine bilderzeugende Struktur ist.
 - 8. Geformter Artikel, umfassend die Zusammensetzung nach Anspruch 1 bis 4.
 - 9. Zusammensetzung nach Anspruch 1 bis 4 sowie 6 bis 8, die gehärtet wurde.

45 Revendications

- 1. Composition polymérisable sous l'effet d'une énergie, comprenant :
 - a) au moins un monomère éthyléniquement insaturé,
 - b) un des éléments suivants :
 - (1) des précurseurs de polyuréthane, lesdits précurseurs de polyuréthane comprenant au moins un monomère additionnel différent de a) qui est au moins un monomère ayant au moins deux groupes isocyanates et au moins un monomère ayant au moins deux atomes d'hydrogène réactifs vis-à-vis des isocyanates,
 - (2) au moins un monomère époxy, différent du monomère de a), et
- c) un agent de durcissement comprenant :
 - (1) un composé organométallique, et
 - (2) un sel onium choisi parmi les composés halonium et les composés cationiques des éléments hypervalents du groupe VI A,

ledit composé organométallique ayant la formule

L1L2L3M

οù

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L¹ représente aucun ou de 1 à 12 ligands apportant des électrons π , qui peuvent être des ligands identiques ou différents les uns des autres, choisis parmi des composés et des groupes acycliques ou cycliques, substitués ou non substitués, et des composés carbocycliques aromatiques et hétérocycliques aromatiques, substitués ou non substitués, dont chacun est capable d'apporter de 2 à 24 électrons π à la couche de valence de M :

 L^2 représente aucun ou de 1 à 24 ligands qui peuvent être identiques ou différents les uns des autres, apportant un nombre pair d'électrons σ , choisis parmi des ligands mono-, bi- ou tridentés, apportant chacun 2, 4 ou 6 électrons σ à la couche de valence de M :

L³ représente aucun ou de 1 à 12 ligands qui peuvent être identiques ou différents les uns des autres, apportant chacun pas plus d'un électron σ à la couche de valence de chaque M;

les ligands L^1 , L^2 et L^3 pouvant être des ligands pontants ou non-pontants ;

M représente 1 à 4 atomes métalliques identiques ou différents les uns des autres, choisis parmi les éléments des groupes périodiques IVB, VB, VIB, VIB et VIII, quand des précurseurs des polyuréthane sont présents, ou des groupes périodiques VB, VIB, VIB et VIII quand un monomère époxy est présent dans la composition polymérisable ;

à la condition que ledit composé organométallique contienne au moins une liaison métal-métal du type σ et L3 ; et à la condition que L1, L2, L3 et M soient choisis de manière à donner une configuration stable.

25 2. Composition selon les revendication 1 où ledit sel onium a la formule II:

AX (II)

où A est un cation iodonium, sulfonium ou diazonium, et X est un contre-ion sulfonate organique ou un contre-ion d'un métal halogéné ou d'un non-métal.

- 3. Composition selon les revendications 1 à 2, où ledit monomère éthyléniquement insaturé est choisi dans l'ensemble constitué par les acrylates, les acrylamides et les composés vinyliques.
- 4. Composition selon les revendications 1 à 3, où lesdits précurseurs de polyuréthane comprennent un mélange de polyisocyanates et de composés portant au moins deux atomes d'hydrogène réactifs vis-àvis des isocyanates, le rapport des groupes isocyanates étant compris entre 1:2 et 2:1.
 - 5. Procédé comprenant les étapes consistant à :
 - a) fournir un mélange polymérisable selon les revendications 1 à 4, et
 - b) laisser le mélange polymériser ou ajouter de l'énergie audit mélange pour effectuer la polymérisation.
- 6. Structure stratifiée comprenant un substrat dont une des faces est revêtue de la composition polymérisable selon les revendications 1 à 4.
 - 7. Structure stratifié selon la revendication 6, qui est une structure pouvant être pourvue d'une image.
 - 8. Article façonné comprenant la composition selon les revendications 1 à 4.
 - 9. Composition selon les revendications 1 à 4 et 6 à 8, qui a été durcie.

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